EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	8	((protect\$3 near1 (tape film layer)) with (wafer ((silicon semiocnductor) near substrate)) with (separat\$3 near (method process))).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:50
L2	10	("5480842" "5776799" "5840614" "6039830" "6048749" "6153536" "6156423" "6238515" "6245677" "6352935").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2007/09/26 20:59
L3	10	("5480842" "5776799" "5840614" "6039830" "6048749" "6153536" "6156423" "6238515" "6245677" "6352935").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2007/09/26 21:05
L4	0	("6716295").URPN.	USPAT	OR	ON	2007/09/26 21:06
L5	1	("5981391").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2007/09/26 21:06
L6	12	("5981391").URPN.	USPAT	OR	ON	2007/09/26 21:11
L7	1	("5344524").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2007/09/26 21:42
L8	9	((protect\$3 near1 (tape film layer)) same (wafer ((silicon semiocnductor) near substrate)) same (separat\$3 near (method process))).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:44
L9	1	8 not 1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:44
L10	4180	438/690,691,465,758,759,761,976. ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ÓΝ	2007/09/26 21:50
L11	54	10 and (protect\$3 near1 (tape film layer)) and (wafer ((silicon semiocnductor) near substrate)) and (separat\$3 with (protect\$3 near1 (tape film layer)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:52

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L12	54	11 not 8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:52
L13	32	235678	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:52
L14	54	12 not 13	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:52
L15	2	"20030064592"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:55
L16	2	"20030062116"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/26 21:55